

Figure 1: UV/VIS spectrum of a film of the compound OTPD, before and after rinsing with THF. The label "only UV" means no conditioning step, the label "150°C + UV" means exposure to light on a hotplate at 150°C.

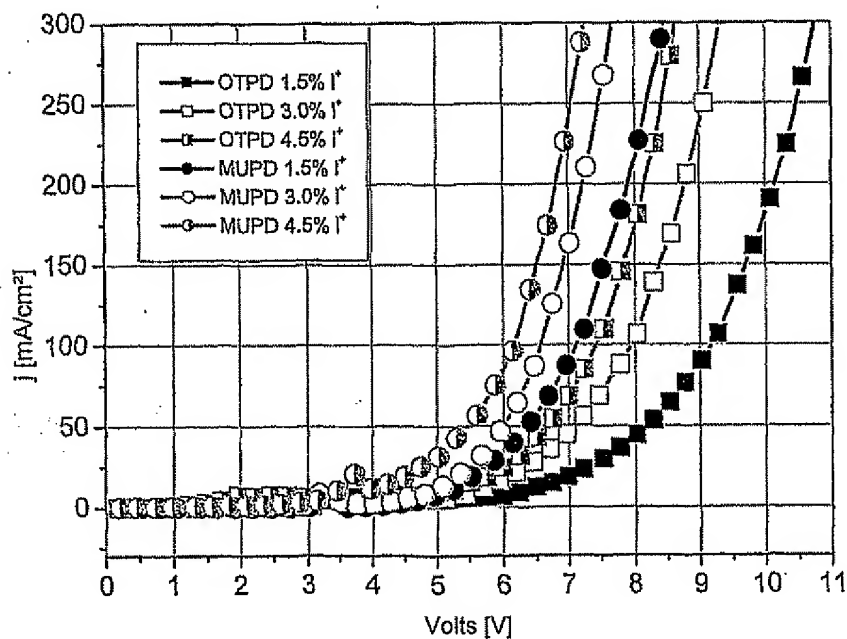


Figure 2: Hole-only diodes of OTPD and MUPD with three different initiator concentrations each.

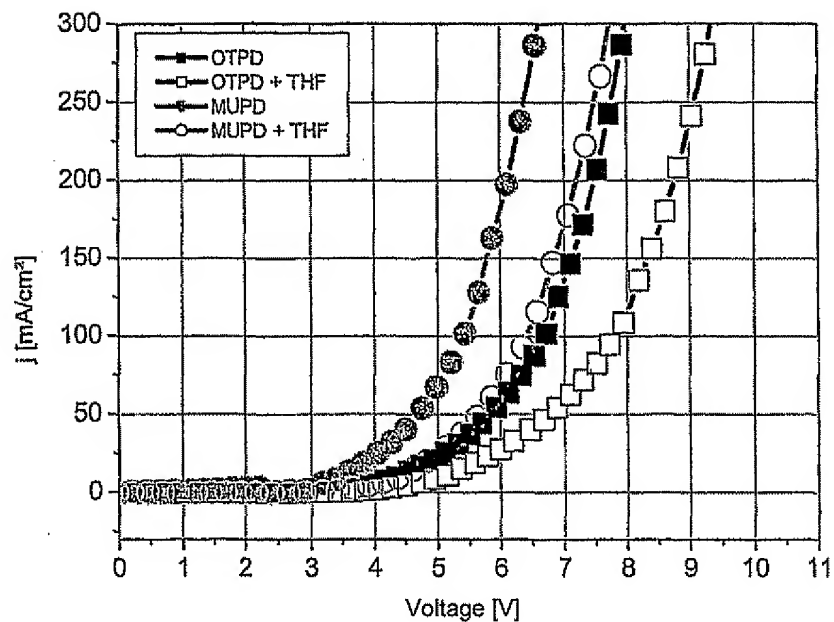


Figure 3: Hole-only diodes of the derivatives **OTPD** and **MUPD**, each with and without rinsing with THF.

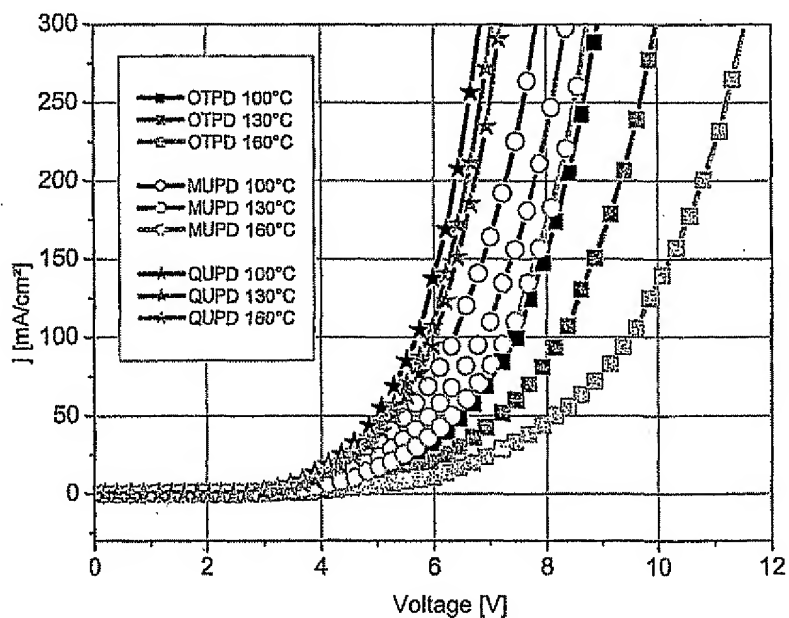


Figure 4: Hole-only diodes of the derivatives **OTPD**, **MUPD** and **QUPD**, each of which has been conditioned at three different temperatures.